



Re application of:
Sandhu et al.

Serial No.: 09/439,314

Filed: November 12, 1999

For: DEVICE FOR IN-SITU CLEANING
OF AN INDUCTIVELY-COUPLED
PLASMA CHAMBER

§ Group Art Unit: 1763
§ Examiner: T. Dang
§ Atty. Docket: 95-0392.02

§ Certificate of Mailing (37 C.F.R. § 1.8)

§ I hereby certify that this correspondence is being deposited with the
§ United States Postal Service as first class mail, postage prepaid, in an
§ envelope addressed to: Commissioner for Patents, Washington, D.C.
§ 20231, on the date below.

§ 10/22/01
§ Date

§ Susan Jerome
§ Signature

#9
1/11/02
MW

PETITION FOR EXTENSION OF TIME UNDER 37 C.F.R. § 1.136(a)

Commissioner for Patents
Washington, D.C. 20231

Dear Sir:

Applicants hereby petition to extend the period for response to the Office Action mailed
May 22, 2001 for two (2) month(s), from August 22, 2001 to October 22, 2001.

Accordingly, the requisite fee is \$ 400. The Commissioner is requested to charge this fee,
and any additional fee which may be required to Micron Technology, Inc. Deposit Account 13-
3092, Order No. 95-0392.02. A duplicate copy of this petition is enclosed.

Respectfully submitted,

Date: 10/22/01

Charles Brantley

Charles B. Brantley, II, Reg. No. 38,086
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